

ward-propagating portion of this fluorescence passes through a long-wave pass filter ($\lambda_{cut-on} = 550\text{nm}$) to a silicon photodiode detector (Hamamatsu, UK). The launch and detection filter combination minimises detection of the LED signal without significant curtailment of the fluorescence signal. The output from the detector is passed to the lock-in amplifier for synchronous detection with the LED pulsing signal.

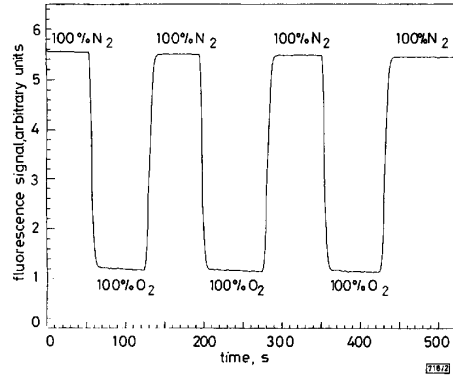


Fig. 2 Sensor response to 100% N_2 and 100% O_2

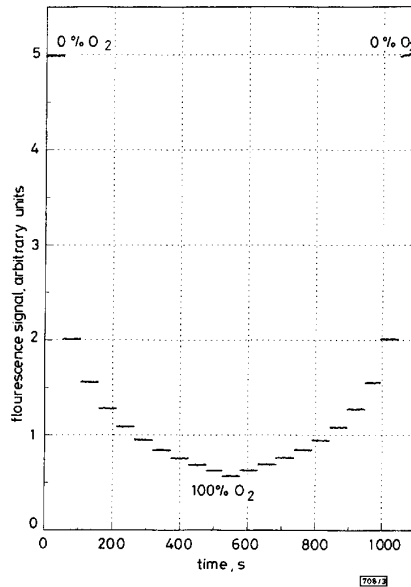


Fig. 3 Sensor calibration data in 10% increments from 0 to 100% oxygen

All measurements were made at atmospheric pressure. The sensor response to alternate environments of 100% N_2 and 100% O_2 , respectively, is shown in Fig. 2. These data show the high level of repeatability of the measurement process and the high signal-to-noise ratio (~ 150 for 100% N_2) achieved with system optimisation. The sensor response time is very short, less than 5s, without removing the contributions of the filling time of the gas chamber and the adjustment time of the mass-flow controllers. Calibration data for the sensor at 10% intervals over the range 0–100% oxygen are shown in Fig. 3. These measurements illustrate the absence of hysteresis over the full concentration range. Furthermore, the inherent nonlinear dependence of the quenching process on oxygen concentration, predicted by eqn. 1, is obvious. The bimolecu-

lar quenching constant k , which characterises the nonlinear response, depends explicitly on the rate of diffusion of the oxygen molecules through the microporous structure. By adjusting the sol-gel process parameters, it is possible to control the coating micro-structure in order to optimise sensitivity in the concentration range of interest.

Conclusion: We have demonstrated the first intrinsic fibre optic oxygen sensor which uses LED excitation and photodiode detection. The results presented show a high level of sensor performance and establish the viability of low-cost portable oxygen sensors based on the sol-gel process. The flexibility of this process enables the tailoring of coatings for specific applications, such as for dissolved oxygen. Finally, the expected commercial availability of blue-green laser diodes in the near future will enable the application of the principles demonstrated here to remote, multiplexed or (quasi-)distributed oxygen sensing.

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Measuring emission cross-section profile of erbium-doped fibre with low input power

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Indexing terms: Fibre lasers, Laser theory, Optical variables measurement

A simple and elegant method is proposed to measure the emission cross-section profile of erbium-doped fibre by using a short piece of erbium-doped fibre with input pump or signal power less than 1mW. Relative error is within 1% over the whole spectrum. The theoretical and experimental results are discussed.

Introduction: The erbium-doped fibre amplifier (EDFA) has been shown to be an effective and promising component for optical fibre communication systems [1]. Accurate emission cross-sections are essential in the modelling of EDFA performance [2]. Previous work used very short EDF length ($< 0.2\text{dB}$ small-signal absorption) pumped with 70mW at 978nm from a Ti:sapphire laser to measure the fluorescence spectrum of the EDF [3]. Recently, we reported that a broadband fluorescence spectrum will be generated in the 1500nm band with low input pump or signal power due to the phonon interaction of Stark energy levels in EDF at room temperature [4]. In this Letter we show that the emission cross-section profile of EDF can be measured by using a short piece of

EDF with low input power at a wavelength in the proximity of the absorption band at long wavelength as well as at short wavelength.

Theory: A homogeneously broadened model is used, where we consider a number of optical beams within the homogeneous bandwidth of the amplifier to resolve the spontaneous emission spectrum [5]. The convective equations describing the spatial development of the pump power P_p and the spontaneous emission powers P_k^\pm copropagating and counterpropagating to the pump in the EDF are

$$\frac{dP_p(z,t)}{dz} = P_p \Gamma_p (\sigma_{ep} N_2 - \sigma_{ap} N_1) - \alpha_{ip} P_p \quad (1)$$

$$\frac{dP_k^\pm(z,t)}{dz} = \pm P_k^\pm \Gamma_k (\sigma_{ek} N_2 - \sigma_{ak} N_1) \pm 2\sigma_{ek} N_2 \Gamma_k h\nu_k \Delta\nu_k \mp \alpha_{ip} P_k^\pm \quad (2)$$

where N_1 and N_2 are the population densities of the ground level and metastable level, σ_{ep} , σ_{ap} , α_p and Γ_p are the emission cross-section, absorption cross-section, intrinsic fibre loss and confinement factor at λ_p , respectively. Eqns. 1 and 2 are solved under the steady-state conditions (i.e. $dN_i/dt = 0$, $i = 1, 2$) to yield the output fluorescence powers.

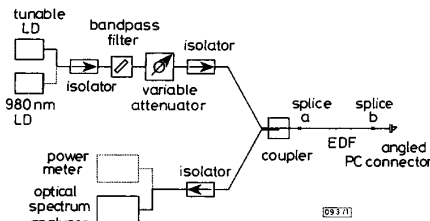


Fig. 1 Experimental setup for measurement of fluorescence spectrum

Experiment: An experimental setup for measuring the fluorescence spectra of EDF similar to that used in [4] is shown in Fig. 1. The input sources were 1532 or 1550 nm from a narrow linewidth external cavity tunable semiconductor laser and 980 nm from a strained multiquantum well laser diode. The optical isolators and an angled PC-type connector were used to avoid reflections from the fibre ends or the grating of the optical spectrum analyser. The output power from the source was coupled by a 2×1 wavelength independent 3 dB optical fibre coupler or a 980/1550 nm dichroic coupler into the erbium-doped fibre. The EDF used in this experiment had a core diameter of 5 μm , an NA of 0.24, a cutoff wavelength of 1.12 μm , and an unpumped attenuation of 8.6 and 4.4 dB/m at 1530 and 1550 nm, respectively. The EDF was cut out a short length at a time from splicing point b then fused again, and the measurement procedures were repeated.

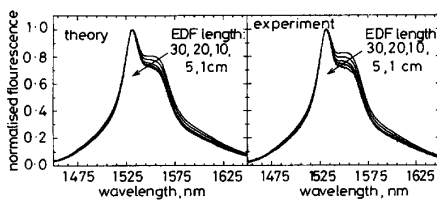


Fig. 2 Theoretical and experimental results of normalised backward fluorescence power spectra for various EDF lengths with -10 dBm input power at 1550 nm

Results and discussion: Fig. 2 shows the theoretical and experimental results of backward fluorescence spectra normalised to their fluorescence peaks with $1/\lambda^3$ wavelength dependence for various EDF lengths with an input power of -10 dBm at 1550 nm. The emission cross-section profile used in the theoretical calculation, also shown as a dashed curve, which overlaps with the 1 cm curve in the left of Fig. 2, was actually obtained from the measured

emission cross-section profile of the 1 cm curve showed in the right of Fig. 2. It can be seen that the profile of the fluorescence closely resembles the emission cross-section as the EDF length shortens. A similar result can be obtained for input wavelength at 1532 and 980 nm. This can be explained by eqn. 2 in that, when the EDF length is short enough, the attenuation of the pump power is negligible and can be assumed to be a constant along the EDF, and for a highly doped EDF the intrinsic fibre loss is negligible when compared with the other two terms. Thus the fluorescence power spectrum can be approximated as

$$P_k^\pm = 2\sigma_{ek} N_2 \Gamma_k h\nu_k \Delta\nu_k L \quad (3)$$

where L is the length of the EDF. Eqn. 3 indicates that the fluorescence power is linearly proportional to α_k , thus the profile of the emission cross-section spectrum can be measured by normalising the fluorescence power spectrum with $\nu\Delta\nu$ or $\Delta\lambda/\lambda^3$.

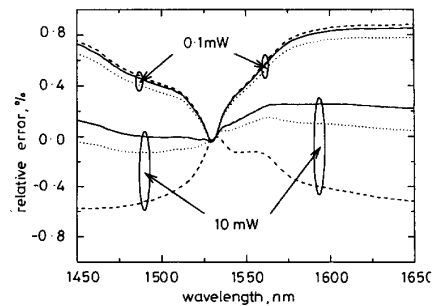


Fig. 3 Spectra of relative error of emission cross-section profile with 1 cm EDF length for 0.1 and 10 mW input power level at various pump wavelengths

— 980 nm
 1532 nm
 — 1550 nm

The relative error of the emission cross-section profile can be defined as the ratio of the difference between the value obtained theoretically and the value used in the theoretical calculations. Fig. 3 shows the percentage of relative error against wavelength for 1 cm EDF length with 0.1 and 10 mW input power. It can be seen that the value of the relative error is less than 1% over the whole spectrum and is smallest at the emission cross-section peak. Also notice that although the EDF is as short as 1 cm, the value of the relative error is higher for 980 nm pumping than that for 1532 or 1550 nm pumping.

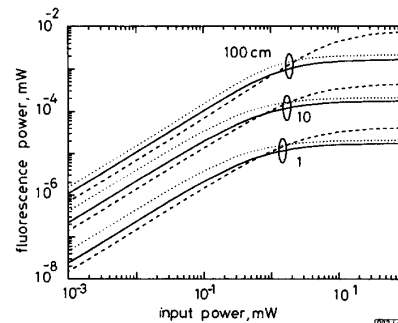


Fig. 4 Fluorescence output power against input pump power at various pump wavelengths for different EDF lengths

— 980 nm
 1532 nm
 — 1550 nm

Fig. 4 shows the theoretical results of the backward fluorescence power against input pump power at 980, 1532 and 1550 nm for

various EDF lengths. It can be seen that the fluorescence output power with 100mW pumping is approximately one order of magnitude larger than that with 0.1mW and is about four times larger than that with 1mW. High pump power around 980nm is not easy to obtain with a semiconductor laser diode, whereas it is much easier to obtain ~1mW power at 1532 or 1550nm. Thus, this method provides a much simpler way to characterise the emission cross-section profile of an EDF.

Conclusions: Measurement of the emission cross-section profile of erbium-doped fibre in the 1500nm band from the fluorescence spectrum with low pump power is theoretically and experimentally investigated. An accurate profile can be obtained with a short length of EDF and with input power less than 1mW at a wavelength of 980nm in the pump band or 1532 or 1550nm in the signal band.

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Very broad reflection bandwidth (44 nm) chirped fibre gratings and narrow bandpass filters produced by the use of an amplitude mask

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Indexing terms: Gratings in fibres, Holographic gratings

Chirped gratings with very broad reflection bandwidths up to 44nm and high reflectivity have been produced holographically in boron-codoped and standard telecommunications fibres which have been hydrogen-soaked. A 2nm wide transmission band has been produced within the broad reflection band by use of an amplitude mask during grating exposure.

Fibre gratings with broad reflection bandwidths have many applications in fibre optic systems including fibre amplifier pump reflectors [1] and gain flattening devices [2], dispersion compensation elements [3], and reflectors for sensor arrays [4]. A large reflection bandwidth may be achieved from a uniform period grating with a very strong coupling coefficient [5], or by the introduction of extrinsic chirp. We have previously reported holographically produced, extrinsically chirped fibre gratings with >95% reflectivity over a 17nm spectral width [1], formed as surface-relief structures in polished fibres. The direct writing technique, whereby gratings are produced holographically by UV-

exposure [6, 7], considerably simplifies the fabrication process.

We report here the fabrication of extrinsically chirped gratings which have FWHM spectral reflection bandwidths of 44nm; these gratings have the broadest bandwidths of any fibre gratings yet reported. We report also the use of an amplitude mask during exposure to produce a 2nm wide transmission band within the broad reflection spectrum of the chirped grating, with anticipated applications in wavelength division multiplexed fibre networks. It has been shown that hydrogen soaking may be used to increase the photosensitivity of low-germania optical fibre [8], and we have established that standard telecommunications fibre (Corning SMF 28) can be sensitised by hydrogen soaking in this way for grating writing.

Broad bandwidth fibre gratings can be made by writing short, 'ultrastrong', uniform period gratings in fibres exhibiting a very high photoinduced index change. This approach has been used to produce gratings with reflection bandwidths of up to 19nm, albeit with significant loss [5]. Methods for fabricating broad bandwidth directly written gratings based on extrinsically chirping the effective grating period by tapering the fibre diameter [9], or by bending the fibre during exposure [10], have used the constant-period interference pattern derived from two plane wavefronts, and have so far yielded smaller bandwidths. However, chirped period gratings with widely controllable characteristics may be formed using interfering wavefronts of dissimilar curvatures [1], and we report the use of this method.

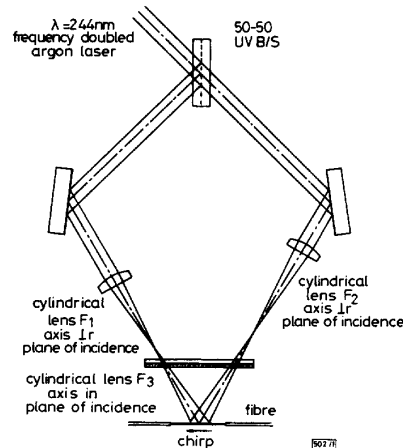


Fig. 1 Holographic system for fibre grating fabrication

The holographic arrangement for fabrication of chirped fibre gratings is shown in Fig. 1. The UV source was an argon laser frequency doubled to 244nm, which had an output power of between 80 and 100mW. Two cylindrical lenses (focal lengths 104 and 100mm) were used to form the curved wavefronts and a cylindrical lens was used to focus the interfering beams onto the fibre. By adjusting the relative positions of the cylindrical lenses the bandwidth of the chirped gratings can be varied from zero chirp to over 100nm.

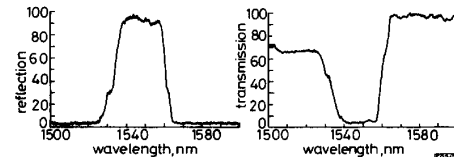


Fig. 2 Reflectivity and transmission of broadband chirped fibre gratings fabricated in hydrogenated standard communications fibre doped optical fibre

The strength of the grating reflectivity is a function of the induced index change, the grating length, and the chirp band-